Special Issue

New Additive Manufacturing Techniques in Manufacturing Systems

Message from the Guest Editors

This Special Issue on "New Additive Manufacturing Techniques in Manufacturing Systems" seeks high-quality works focusing on the latest novel advances in additive manufacturing. Topics include, but are not limited to:

- In situ process monitoring/control;
- Numerical simulation;
- Customized additive manufacturing processes;
- Feedstock material development;
- Microstructure engineering in AM;
- Post-processing techniques applied to AM;
- Hybrid processes;
- The behavior of parts fabricated by AM;
- Synergy between AM and traditional processes;
- Artificial intelligence applied to AM.

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Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

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